



HAL
open science

Ultrasound-Assisted Soil Washing Process for the Removal of Heavy Metals from Clays References

Sophie Herr, Antoine Leybros, Barre Yves, Sergey I. Nikitenko, Rachel Pflieger

► **To cite this version:**

Sophie Herr, Antoine Leybros, Barre Yves, Sergey I. Nikitenko, Rachel Pflieger. Ultrasound-Assisted Soil Washing Process for the Removal of Heavy Metals from Clays References. 8th International Conf. On Environmental Pollution, Treatment and Protection, Mar 2023, Lisbonne, Portugal. hal-04666581

HAL Id: hal-04666581

<https://hal.umontpellier.fr/hal-04666581v1>

Submitted on 1 Aug 2024

HAL is a multi-disciplinary open access archive for the deposit and dissemination of scientific research documents, whether they are published or not. The documents may come from teaching and research institutions in France or abroad, or from public or private research centers.

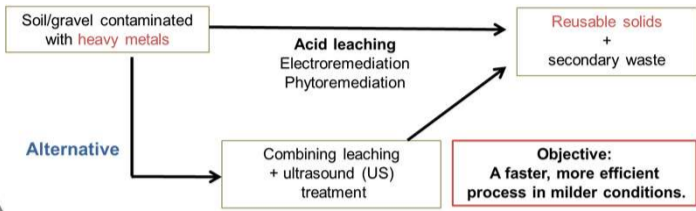
L'archive ouverte pluridisciplinaire **HAL**, est destinée au dépôt et à la diffusion de documents scientifiques de niveau recherche, publiés ou non, émanant des établissements d'enseignement et de recherche français ou étrangers, des laboratoires publics ou privés.

Context

Past human activities:

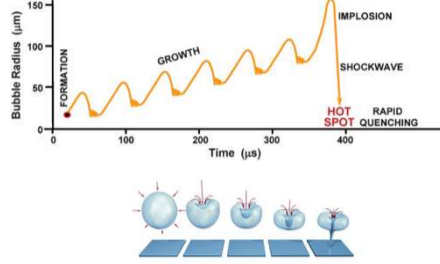
- Agriculture (pesticides, fertilizers...)
- Industrial activity (mining, paint production, battery production...)

are source of trace metals harmful to humans and the environment



Acoustic Cavitation

20 kHz – 1 MHz



Erosion and Fragmentation

- Erosion and Fragmentation
- Decrease of the diffusion layers
- Acceleration of the mass transfer

A few recent studies combined leaching with ultrasound

Reference	Target metal(s)	Solvent
Choi et al., 2021	Cu, Pb, Zn	EDTA/HCl
Son et al., 2019	Cu, Pb, Zn	HCl
Park et al., 2017*	Cu, Pb, Zn	HCl
Kim et al., 2016	Cu, Zn	HCl
Hwang et al., 2007	Cu, Pb, Cd, Zn	EDTA/citric acid

US/mixing > conventional mixing in terms of

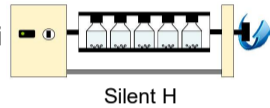
- ✓ removal efficiency
- ✓ consumption of chemicals

Attributed to better agitation (macroscale) & sonophysical effects (microscale)

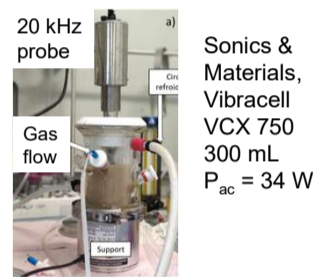
- However:
- Kinetic aspects neglected
 - Poor soil characterisation

Methods

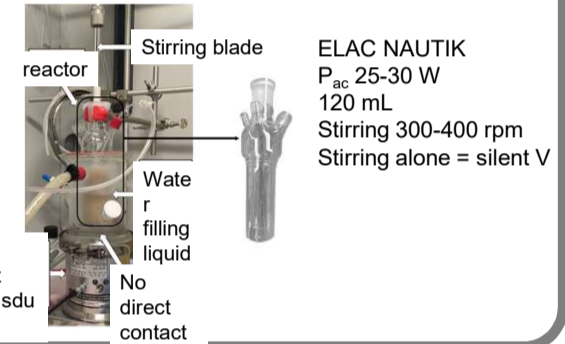
- Vermiculite clay was grinded, sieved (<100 µm) and contaminated with Zn or Ni by contacting it with Zn or Ni nitrates + NaNO₃ 10⁻² M solutions at pH 4
- Initial metal content: 30-38 mg/g
- ICP-AES was used to quantify metal in solution
- Leaching solution HCl 0.1 M
- Temperature was kept around 20° C
- Tessier sequential extraction protocol was used to monitor metal repartition in the solid
- Laser granulometry for size distribution



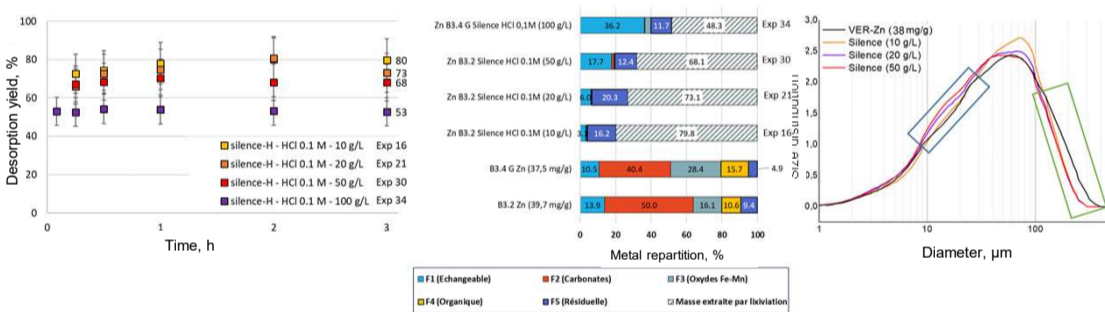
Low frequency US: 20 kHz



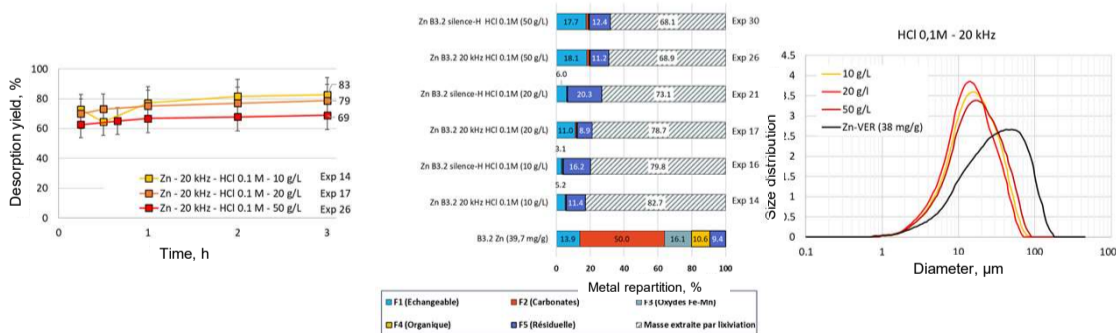
High-frequency US: 362 kHz



Results - Zn



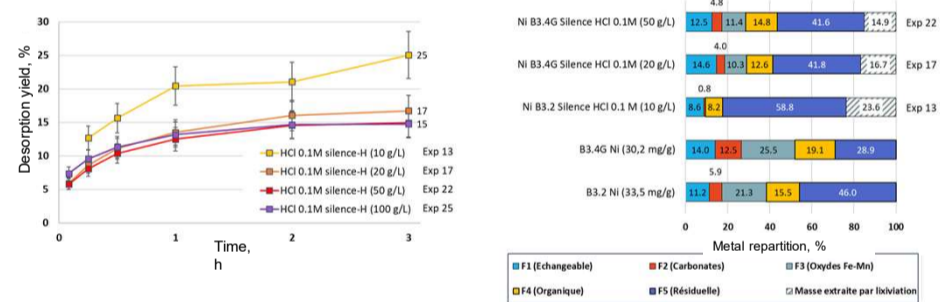
Initially, Zn mostly in F2 (+ F3)
 Silent, HCl 0.1M: removal of F2-F3-F4
 F1 ↓ at low m/V, ↑ at high ones due to fragmentation creating new adsorption sites
 F5 ↑ indicating readsorption



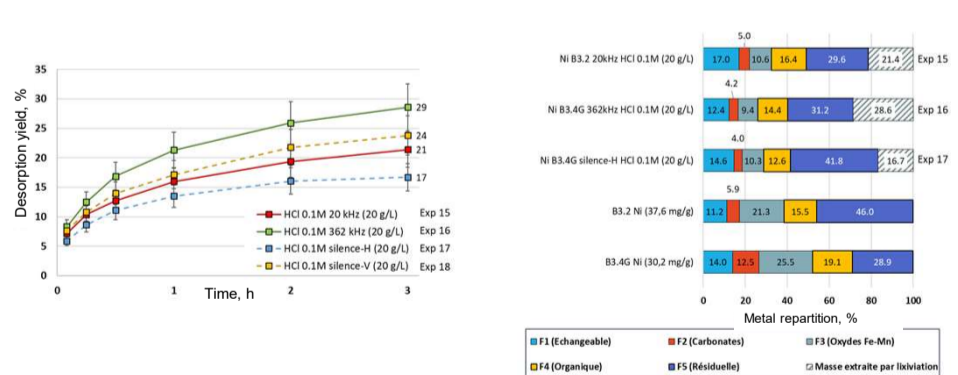
20 kHz, HCl 0.1 M: removal of F2-F3-F4, similarly to silent conditions
 50 g/L similar to silent conditions
 10-20 g/L: higher desorption from F5, but F1 ↑ due to fragmentation (new sorption sites)

At high-frequency US, fragmentation is limited, negative effects of US disappear.
 362 kHz similar to silent conditions, in terms of depollution yields, Zn repartition and size distribution.

Results - Ni



Very different behaviour compared to Zn: Ni mostly in F5 (+ F4)
 ⇒ Much lower desorption yield
 ⇒ HCl 0.1 M silent conditions: removal of only part of F2-F3-F4



In the presence of US, higher desorption from F5
 20 kHz: F1 ↑ due to fragmentation
 362 kHz: after 1 hour +30% compared to silent conditions

Outlook and conclusion

- Zn and Ni show very different repartitions in the clay (Tessier sequential extraction protocol) and consequently very different leaching behaviours with HCl 0.1 M: fast and high yield for Zn, slow and less efficient for Ni.
- Zn: negative impact of 20 kHz, due to creation of new adsorption sites; non-significant one from 362 kHz.
- Ni: similar negative impact of 20 kHz, though higher desorption from F5; positive effect (+30% after 1 hour) of 362 kHz US.

References

- Choi, J., Lee, D., & Son, Y. (2021). *Ultrason Sonochem*, 74, 105574.
 *Park, B., & Son, Y. (2017). *Ultrason Sonochem*, 35(Pt B), 640-645.
 Son, Y., Lee, D., Lee, W., Park, J., Hyoung Lee, W., & Ashokkumar, M. (2019). *Ultrason Sonochem*, 58, 104599.
 Kim, S., Lee, W., & Son, Y. (2016). *Jpn. J. Appl. Phys.*, 55(7S1), 07KE04.
 Hwang, S.-S., Park, J.-S., & Namkoong, W. (2007). *J Ind Eng Chem*, 13(4), 650-656

Acknowledgements

We thank CEA PFRAC/TEENV for financial support.